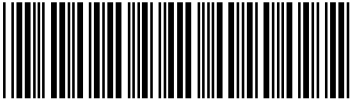


<b>Search Notes</b>  	<b>Application/Control No.</b>  09313659	<b>Applicant(s)/Patent Under Reexamination</b>  YANG ET AL.
	<b>Examiner</b>  Abul Kalam	<b>Art Unit</b>  2814

SEARCHED			
Class	Subclass	Date	Examiner
438	231	11/18/2010	ak

SEARCH NOTES		
Search Notes	Date	Examiner
Update search: Class/Subclass 438/303,305-307, 257/336,e21.626	11/18/2010	ak
Key search terms: sidewall spacer, lightly doped drain (LDD), impurity, dopant, annealing, diffusing	11/18/2010	ak
Forward/Backward Citation of Patents	11/18/2010	ak
Interference Search: ((spacer near5 mask) with ((first and second and third) near2 gate)).clm.	11/18/2010	ak

INTERFERENCE SEARCH			
Class	Subclass	Date	Examiner
438	231	11/18/2010	ak

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